

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Peter Rabkin et al.

Application No.: 09/994,545

Filed: November 26, 2001

For: POLYSILICON LAYERS STRUCTURE AND

METHOD OF FORMING SAME

Examiner: Im, Junghwa M

Art Unit: 2811

#5 Election Franks

7-19-02

RESPONSE TO RESTRICTION

<u>REQUIREMENT</u>

June 26, 2002

RECEIVED
JUL 10 2002

Assistant Commissioner for Patents Washington, D.C. 20231

Sir:

In response to the restriction requirement mailed May 6, 2002, appl ants elect to prosecute claims 17-35 (Group I), drawn to a semiconductor device.

Respectfully submitted,

Barmak Sani Reg. No. 45,068

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